

### New Release

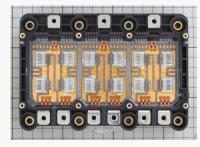
#### **LTEC Corporation**

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### FUJI ELECTRIC 6MBI800XV-075V-01 IGBT MODULE FOR EV & HEV DETAILED ANALYSIS REPORTS

**February 2020.** LTEC Corporation released three analysis reports (structure, IGBT die, and process flow and electrical characteristics) of the Fuji Electric IGBT module. This module is for automotive application, Vces=750V, Ic=800A. The IGBT die is a 7<sup>th</sup> generation X series Reverse Conducting device (RC-IGBT).







Module

Module inside

**IGBT** die image

#### Report contents

- Layout, the device structure, the internal configuration of the cooler, and an analysis of the heat removal mechanism.
- Planar layout, cross section, EDX analysis of the RC-IGBT, and die structure analysis including analysis of the FWD regions.
- Process analysis report, including process technology of the RC-IGBT
- Estimate of the number of masks and the manufacturing process flow. The integration of the IGBT, the Free Wheeling Diode and temperature sensors.
- Ic-Vce characteristics, off-state collector leakage current and breakdown voltage, extraction of the activation energy from the temperature dependency of offstate leakage current.
- Comparison with Infineon IGBT7.

Module structure analysis report: \$3,500 IGBT die analysis: \$5,800 Process and electrical characteristics analysis: \$4,600

Note: The report price may change over time. For current price contact info@ltecusa.com.

19G-0004-1



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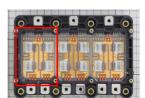
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#### Excerpts from the module structural analysis report

(Report in English)



#### 3-1. モジュール内部観察



#### X方向寸法

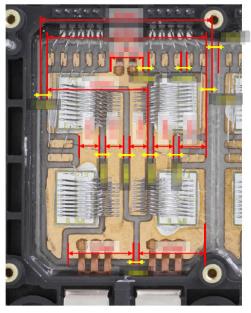


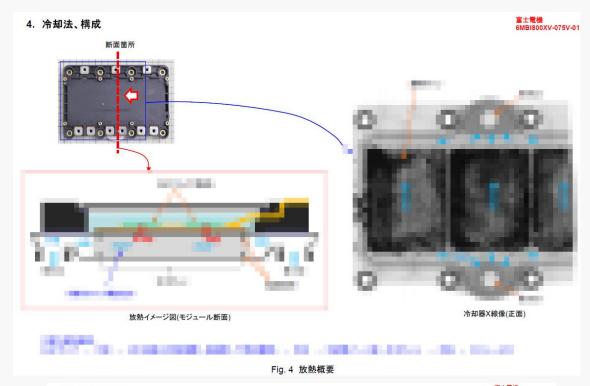
Fig. 3-1-6 モジュール内部拡大



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#### Excerpts from the module structural analysis report

(Report in English)

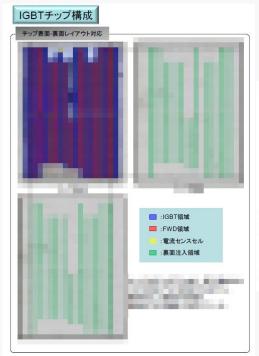


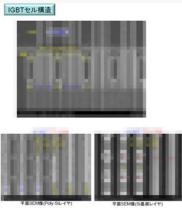


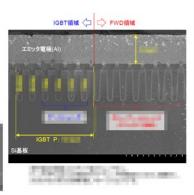


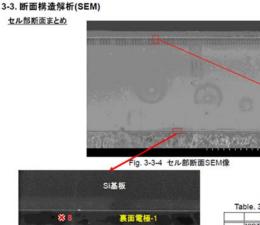
#### Excerpts from the die structure analysis report

(Report in English)

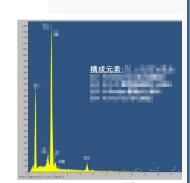












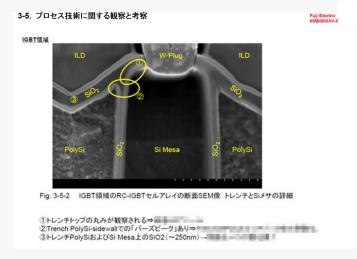






#### Excerpts from the process and device characterization report

(Report in English)

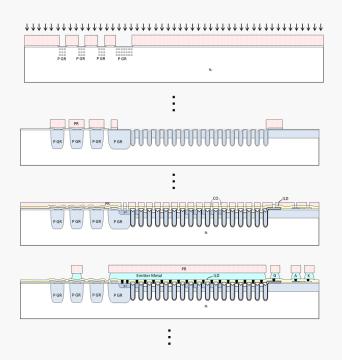


4. 製造プロセスフロー解析 4-1. Si-RC-IGBTのフロントエンドウェーハプロセスフロー(推定)

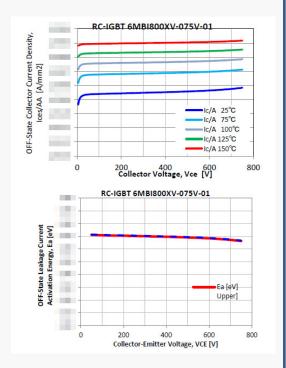


Wafer processing up to back-metallization: photo/masking steps

◆チッププロセスレベル: 枚マスク(層)



Process flow sequence diagram



Off-state collector leakage current per unit area and extraction of the activation energy



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